

SILICON GATE MOS

DESCRIPTION

The Signetics 1103-1 is designed for main memory applications where high performance, low cost and large bit storage are important design objectives. It is a 1024 word by 1 bit random access memory element using enhancement mode P-channel MOS devices integrated on a monolithic array. It is fully decoded, permitting the use of an 18-pin dual in-line package. The dynamic circuitry dissipates significant power only during precharge. Information stored in the memory is nondestructively read. Refreshing of all 1024 bits is accomplished in 32 read cycles and is required every two milliseconds. A separate cenable (chip enable) lead allows easy selection of an individual package when outputs are OR-tied. Use Signetics 8T28 Sense Amp, and 3207 Clock Driver.

FEATURES

- **LOW POWER DISSIPATION – DISSIPATES POWER PRIMARILY ON SELECTED CHIPS**
- **ACCESS TIME – 150 nsec.**
- **CYCLE TIME – 340 nsec.**
- **REFRESH PERIOD – 1 MILLISECOND FOR 0-55°C AMBIENT**
- **OR-TIE CAPABILITY**
- **SIMPLE MEMORY EXPANSION WITH CHIP ENABLE**
- **FULLY DECODED – ON-CHIP ADDRESS DECODE**
- **INPUTS PROTECTED – ALL INPUTS HAVE PROTECTION AGAINST STATIC CHARGE**
- **LOW COST PACKAGING – 18 PIN SILICONE AND 18 PIN CERAMIC DUAL IN-LINE**

APPLICATIONS

CORE MEMORY REPLACEMENT
BUFFER STORES
MAIN MEMORY

PROCESS TECHNOLOGY

The use of Signetics' unique silicon gate low threshold process allows the design and production of higher performance MOS circuits and provides higher functional density on a chip than other MOS technologies.

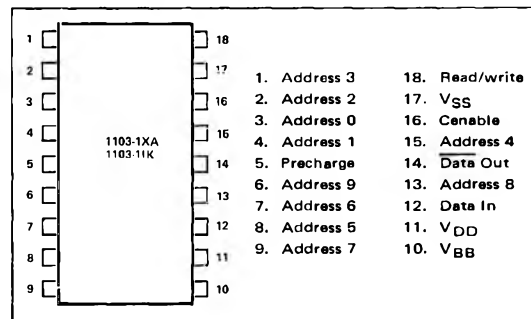
SILICON PACKAGING

Low cost silicone DIP packaging is implemented and reliability is assured by the use of Signetics unique silicon gate MOS process technology. Unlike the standard metal gate MOS process, the silicon material over the gate oxide passivates the MOS transistors, and the deposited dielectric

SILICONE PACKAGING (Cont'd)

material over the silicon gate-oxide substrate structure provides an ion barrier. In addition, Signetics proprietary surface passivation and silicone packaging techniques result in a MOS circuit with inherent high reliability and demonstrating superior moisture resistance, mechanical shock and ionic contamination barriers.

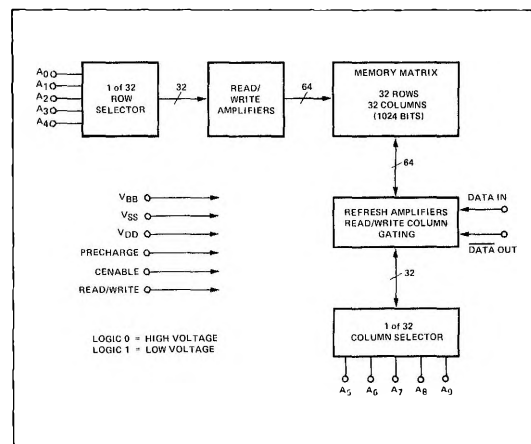
PIN CONFIGURATION (Top View)



PART IDENTIFICATION TABLE

TYPE	PACKAGE	OP. TEMP RANGE
1103-1XA	18-Pin DIP Silicone	0–55°C
1103-11K	18-Pin DIP Ceramic	0–55°C

BLOCK DIAGRAM



MAXIMUM GUARANTEED RATINGS (8)

Operating Ambient Temperature	0°C to 55°C	Supply Voltages V_{DD} and V_{SS}	
Storage Temperature	-65°C to +150°C	with Respect to V_{BB}	-25V to 0.3V
All Input or Output Voltages with Respect to the Most Positive Supply Voltage, V_{BB}		Power Dissipation	1.0W
	-25V to 0.3V		

D.C. AND OPERATING CHARACTERISTICS

$T_A = 0^\circ\text{C}$ to -55°C , $V_{SS}^{(1)} = 19\text{V} \pm 5\%$, $(V_{BB} - V_{SS})^{(6)} = 3\text{V}$ to 4V , $V_{DD} = 0\text{V}$ unless otherwise specified (Note 7).

SYMBOL	TEST	MIN.	TYP.	MAX.	UNIT	CONDITIONS
I_{LI}	Input Load Current (All input pins)			10	μA	$V_{IN} = 0\text{V}$, $T_A = 25^\circ\text{C}$
I_{LO}	Output Leakage Current			10	μA	$V_{OUT} = 0\text{V}$, $T_A = 25^\circ\text{C}$
I_{BB}	V_{BB} Supply Current			100	μA	
$I_{DD1}^{(2)}$	Supply Current During t_{PC}		45	60	mA	All Addresses = 0V Precharge = 0V Cenable = V_{SS} ; $T_A = 25^\circ\text{C}$
$I_{DD2}^{(2)}$	Supply Current During t_{OV}		50	68.5	mA	All addresses = 0V Precharge = 0V Cenable = 0V; $T_A = 25^\circ\text{C}$
$I_{DD3}^{(2)}$	Supply Current During t_{POV}		8.5	11	mA	Precharge = V_{SS} Cenable = 0V; $T_A = 25^\circ\text{C}$
$I_{DD4}^{(2)}$	Supply Current During t_{CP}		3	4	mA	Precharge = V_{SS} Cenable = V_{SS} ; $T_A = 25^\circ\text{C}$
$I_{DD}^{(5)AV}$	Average Supply Current		20	23	mA	Precharge Width = 150ns @ 50% Cycle Time = 340 ns; $T_A = 25^\circ\text{C}$
V_{IL1}	Input Low Voltage (All address and data-in lines)	$V_{SS}-20$		$V_{SS}-18$	V	
V_{IH1}	Input High Voltage (All Inputs)	$V_{SS}-1$		$V_{SS}+1$	V	
I_{OH1}	Output High Current	1.15	1.3	7.0	mA	$T_A = 25^\circ\text{C}$ $T_A = 55^\circ\text{C}$ $T_A = 25^\circ\text{C}$ $T_A = 55^\circ\text{C}$
I_{OH2}	Output High Current	0.9	1.15	7.0	mA	
I_{OL}	Output Low Current	See Note 3				
V_{OH1}	Output High Voltage	115	130	700	mV	
V_{OH2}	Output High Voltage	90	115	700	mV	
V_{OL}	Output Low Voltage	See Note 3				

NOTES:

1. The V_{SS} current drain is equal to $(I_{DD} + I_{OH})$ or $(I_{DD} + I_{OL})$.
2. See Supply Current vs. Temperature (p. 3) for guaranteed current at the temperature extremes. These values are taken from a single pulse measurement.
3. The output current when reading a low output is the leakage current of the 1103-1 plus external noise coupled into the output line from the clocks. V_{OL} equals I_{OL} across the load resistor.
4. This value of load resistance is used for measurement purposes. In applications the resistance may range from 100Ω to $1\text{ k}\Omega$.
5. This parameter is periodically sampled and is not 100% tested.
6. $(V_{BB} - V_{SS})$ supply should be applied at or before V_{SS} .
7. Manufacturer reserves the right to make design and process changes and improvements.
8. Stresses above those listed under "Maximum Guaranteed Rating" may cause permanent damage to the device. This is a stress rating only and functional operation of the device at these or at any other condition above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

AC CHARACTERISTICS $T_A = 0^\circ\text{C}$ to $+55^\circ\text{C}$; $V_{SS} = 19 \pm 5\%$, $(V_{BB} - V_{SS}) = 3.0\text{V}$ to 4.0V , $V_{DD} = 0\text{V}$

READ, WRITE, AND READ/WRITE CYCLE

SYMBOL	TEST	MIN.	TYP.	MAX.	UNIT	CONDITIONS
t_{REF}	Time Between Refresh			1	ms	
t_{AC}	Address to Cenable Set Up Time	30			ns	
t_{CA}	Cenable to Address Hold Time	10			ns	
t_{PC}	Precharge to Cenable Delay	60			ns	
t_{OVL}	Precharge & Cenable Overlap, Low	5		30	ns	
t_{CP}	Cenable to Precharge Delay	40			ns	
t_{OVH}	Precharge & Cenable Overlap, High			85	ns	

READ CYCLE

SYMBOL	TEST	MIN.	TYP.	MAX.	UNIT	CONDITIONS
$t_{RC}^{(1)}$	Read Cycle	300			ns	$t_r = 20\text{ ns}$ $C_{LOAD} = 50\text{ pF}$ $R_{LOAD} = 100\Omega$ $V_{REF} = 80\text{ mV}$
t_{POV}	Precharge to End of Cenable	115		500	ns	
$t_{PO}^{(1)}$	End of Precharge to Output Delay			75	ns	
$t_{ACC1}^{(1)}$	Address to Output Access	150			ns	
$t_{ACC2}^{(1)}$	Precharge to Output Access	180			ns	

WRITE OR READ/WRITE CYCLE

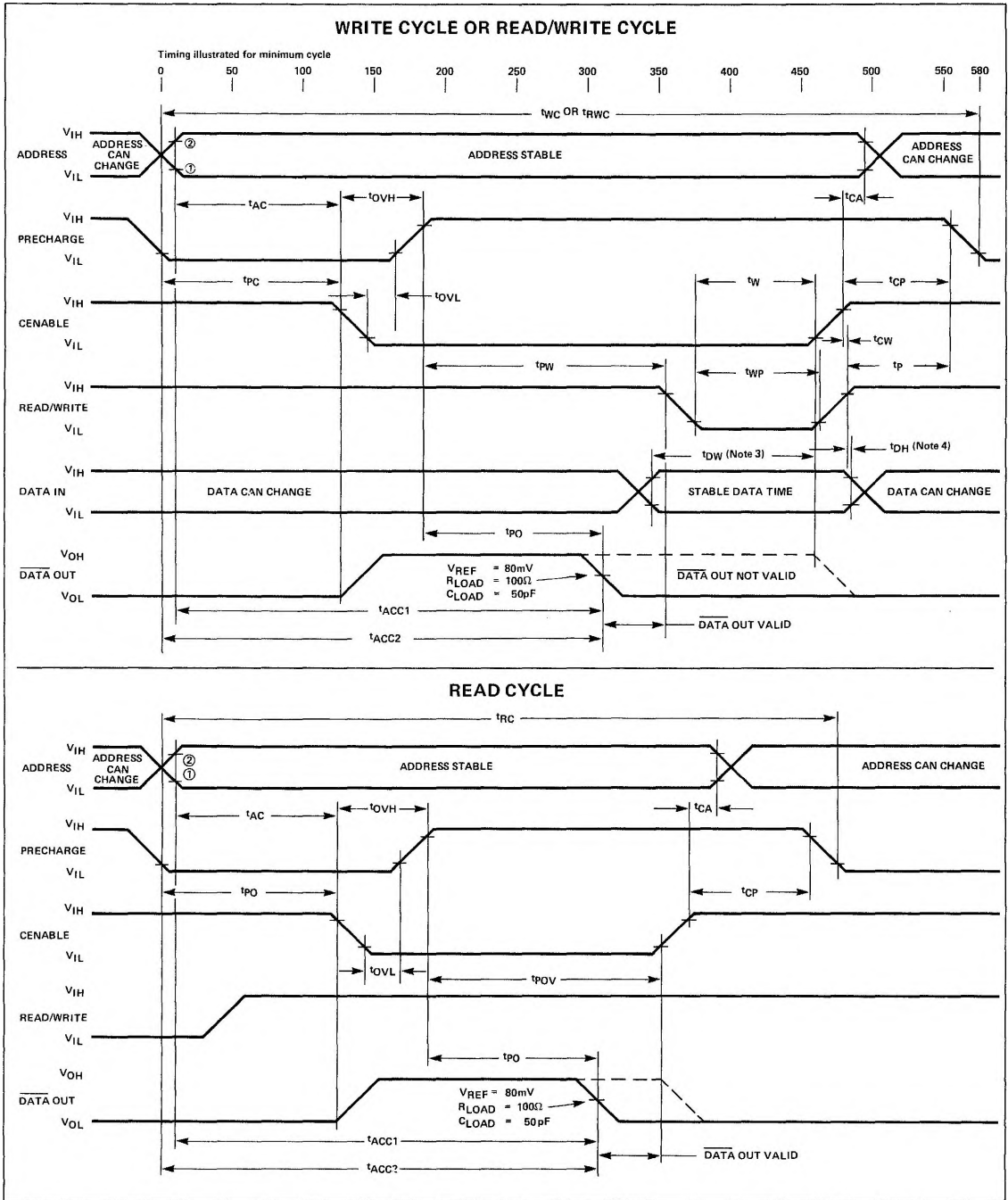
SYMBOL	TEST	MIN.	TYP.	MAX.	UNIT	CONDITIONS
t_{WC}	Write Cycle	340			ns	$t_r = 20\text{ ns}$
$t_{RWC}^{(1)}$	Read/Write Cycle	340			ns	
t_{PW}	Precharge to Read/Write Delay	115		500	ns	
t_{WP}	Read/Write Pulse Width	20			ns	
t_W	Read/Write Set Up Time	20			ns	
t_{DW}	Data Set Up Time	40			ns	
t_{DH}	Data Hold Time	10			ns	
$t_{PO}^{(1)}$	End of Precharge to Output Delay			75	ns	$C_{LOAD} = 50\text{ pF}$ $R_{LOAD} = 100\Omega$ $V_{REF} = 80\text{ mV}$
t_p	Time to Next Precharge	0			ns	
t_{CW}	Read/Write Hold Time			15	ns	

CAPACITANCE (note 2)

SYMBOL	TEST	MIN.	TYP.	MAX.	UNIT	CONDITIONS
C_{AD}	Address Capacitance		5	7	pF	$V_{IN} = V_{SS}$ $V_{IN} = V_{SS}$ $V_{IN} = V_{SS}$ $V_{IN} = V_{SS}$ $V_{IN} = V_{SS}$ $V_{IN} = V_{SS}$ $V_{OUT} = 0\text{V}$ $f = 1\text{ MHz}$ All Unused Pins are at A.C. Ground
C_{PR}	Precharge Capacitance		15	18	pF	
C_{CE}	Cenable Capacitance		15	18	pF	
C_{RW}	Read/Write Capacitance		11	15	pF	
C_{IN1}	Data Input Capacitance		4	5	pF	
C_{IN2}	Data Input Capacitance		2	4	pF	
C_{OUT}	Data Output Capacitance		2	3	pF	

(1) These times will degrade by 35 ns if a V_{REF} point of 40 mV is chosen instead of the 80 mV point defined in this specification.
 (2) This parameter is periodically sampled and is not 100% tested. It is measured at worst case operating conditions. Capacitance measurements for plastic packages only.

TIMING DIAGRAM



NOTES:

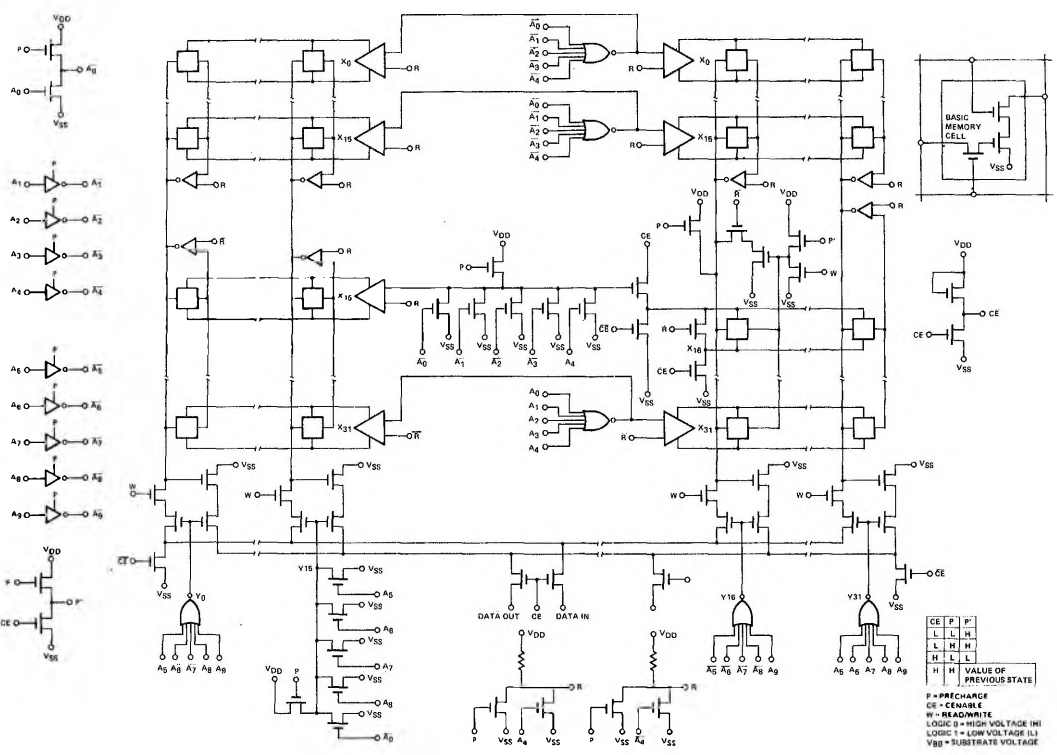
- ① $V_{DD} + 2V$
- ② $V_{SS} - 2V$
- ③ t_{DW} is referenced to point ① of the rising edge of enable or read/write whichever occurs first.
- ④ t_{DH} is referenced to point ② of the rising edge of enable or read/write whichever occurs first.

CIRCUIT SCHEMATIC

A ₀	P	X ₀
L	L	H
H	H	L
H	L	H
L	H	L
L	L	H
H	H	L
H	L	H
L	H	L
L	L	H
H	H	L
H	L	H
L	H	L
L	L	H
H	H	L
H	L	H
L	H	L
L	L	H

VALUE OF PREVIOUS STATE

L = LOW VOLTAGE
H = HIGH VOLTAGE



CE	P	P
L	L	H
L	L	H
H	L	L
H	L	L
L	L	H
L	L	H
H	L	L
H	L	L
L	L	H
L	L	H
H	L	L
H	L	L
L	L	H
L	L	H

VALUE OF PREVIOUS STATE

P = PRECHARGE
CE = CHIP ENABLE
W = READ/WRITE
LOGIC 0 = HIGH VOLTAGE IN
LOGIC 1 = LOW VOLTAGE IN
V_{BB} = SUBSTRATE VOLTAGE